

Performance Enhancement of Quantum Dot Sensitized Solar Cells under TiO₂ Nanotube Arrays Membranes Optimization

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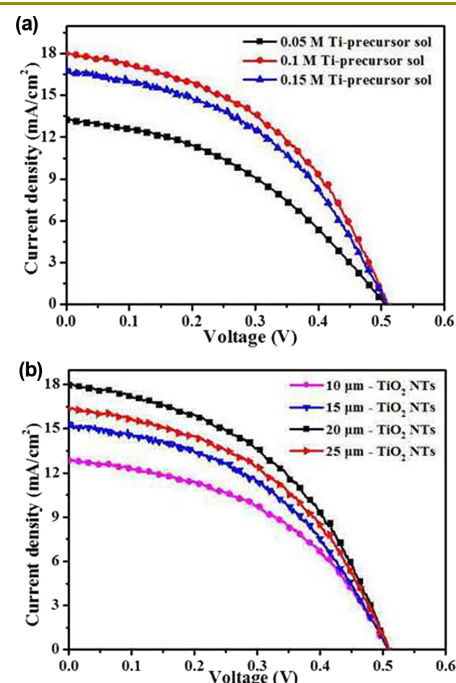
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One-dimensional single crystalline TiO₂ nanotube arrays with different length are prepared, and transferred onto the FTO glass substrate with different concentration of Ti-precursor. The relationships between the concentration of Ti-precursor and the optical properties, as well as the photovoltaic performance of the as-prepared solar cells have been investigated. The optical absorption intensity is obviously enhanced and optical absorption edge is expanded to 800 nm for the CdSe/CdS/TiO₂ NTs solar cells. In addition, 20 μm - CdSe/CdS/TiO₂ NTs solar cells with 0.1 M Ti-precursor have the great photovoltaic conversion efficiency of 4.18%. The excellent photovoltaic performance is attributed to the suitable TiO₂ connection layer from 0.1 M Ti-precursor and length of TiO₂ NTs, which greatly enhances the electron-hole generation and charge transfer performance in the solar cells. Finally, the photovoltaic efficiency of the as-fabricated solar cells can be further enhanced to 4.51% through the ZnS passivation layer deposition.

Keywords: CdSe/CdS quantum dots sensitized solar cells, TiO₂ nanotube arrays, concentration of Ti-precursor, length of TiO₂ nanotubes, photovoltaic performance enhancement



1. INTRODUCTION

Since the semiconductor quantum dots (QDs) been discovered, its unique properties of tunable band gap, high absorption coefficient, ultrafast electron transfer, quantum dots size-effect and multiple exciton generation have been widely employed to fabricate different kinds of optical-electronic devices.^[1-7] Recently, quantum dot sensitized solar

cells (QDSSCs) have become an important research area for the next generation photovoltaic devices. Various kinds of QDs such as CdX (X=S, Se, Te), PbX (X=S, Se, Te), CuInX₂ (X=S, Se), *et al.* have been investigated to improve the photovoltaic efficiency of QDSSCs.^[8-10] In recent researches, it is found that PbX (X=S, Se, Te) and CuInX₂ (X=S, Se) system QDs have the great ultraviolet and visible light absorption properties, which can be employed for fabricating the excellent photovoltaic devices.^[11,12] Due to the excellent optical properties of CdX (X=S, Se, Te) based QDs, the better photovoltaic performance have been obtained by

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optimize CdSe/CdS quantum dot sensitized solar cells.^[13] However, the photovoltaic performance of these QDSSCs still needs to be improved. Therefore, it is still important for the further investigations on the CdSe/CdS QDSSCs to achieve a better photovoltaic efficiency.

In addition to QDs, the materials and structure of the basic photo-electrode also play an important role in QDSSCs. Traditionally, TiO₂ nanoparticle films have been employed as be the photo-electrodes of QDSSCs. However, the loss of the electrons at the grain boundaries in the TiO₂ nanoparticle films is inevitable, which will induce the electron-hole recombination in the solar cell system.^[14] Therefore, many investigations have been focused on the one-dimensional single crystalline nanostructure to enhance the performance of the charge transfer, such as TiO₂ nanorods (NRs), nanowires (NWs) and nanotubes (NTs).^[15-17] For comparison, TiO₂ NTs have larger surface area, and the unique tube structure can provide large area for QDs deposition, which would lead to better excellent photovoltaic performance. In traditional preparations, TiO₂ NTs are prepared on the non-transparent substrates, which can not illuminate from the back side. In order to solve this problem, the TiO₂ NTs have been detached as the membranes from the non-transparent substrates to transfer onto the transparent substrates for solar cells.^[18] However, the structure and combination of the photo-electrodes still influence the photovoltaic performance of the QDSSCs. Therefore, it is significantly important to optimize the nanostructure of the TiO₂ NTs photo-electrodes in the QDSSCs system.

Herein, the TiO₂ NTs arrays were firstly prepared on the Ti substrate by anodization process, then transferred onto the FTO conducting glass through the TiO₂ sol. CdSe/CdS QDs were deposited on the TiO₂ NTs arrays by the successive ionic layer absorption and reaction (SILAR) process. The optimizations of the QDSSCs with different concentration

of TiO₂ sol and length of TiO₂ NTs had been investigated to obtain the better photovoltaic performance of the QDSSCs.

2. EXPERIMENTAL PROCEDURE

2.1 Preparation of TiO₂ NTs arrays electrodes

TiO₂ NTs arrays were prepared on the FTO conducting glass by two-step process. Firstly, TiO₂ NTs arrays were prepared by the traditional anodization process on Ti substrate in the electrolyte consisting of 0.75 wt% distilled (DI) water and 0.25 wt% ammonium fluoride (NH₄F) in ethylene glycol (EG) at 60 V for 2-6 h (As shown in Fig. 1a and Fig. 1b). The different length of TiO₂ NTs was prepared with different anodization time. Afterward, the as-prepared samples were washed with DI water and ethanol to remove the impurities. Then the samples were dried at 80 °C before annealed at 500 °C for 1 h with the heating rate of 1 °C/min at ambient condition. Secondly, the annealed samples were anodized in the same fresh electrolyte at 60 V for another 30 min and washed with DI water. Whereafter, 10 wt% H₂O₂ solution was employed to detach the TiO₂ NTs array membranes from Ti substrate by putting the as-prepared samples into this solution for a few minutes (As shown in Fig. 1c). Then the TiO₂ NTs array membranes were adhered on the FTO conducting glass through a drop of TiO₂ sol consisting of titanium (IV) isopropoxide ethanol solution with different concentration of 0.05 M, 0.1 M and 0.15 M (As shown in Fig. 1d). After dried at 80 °C, the samples were annealed at 500 °C for 1h with the heating rate of 1 °C/min at ambient condition again to form the TiO₂ NTs arrays electrode.

2.2 Fabrication of CdSe/CdS QDs sensitized TiO₂ NTs solar cells

CdSe/CdS QDs were deposited on TiO₂ NTs electrodes by

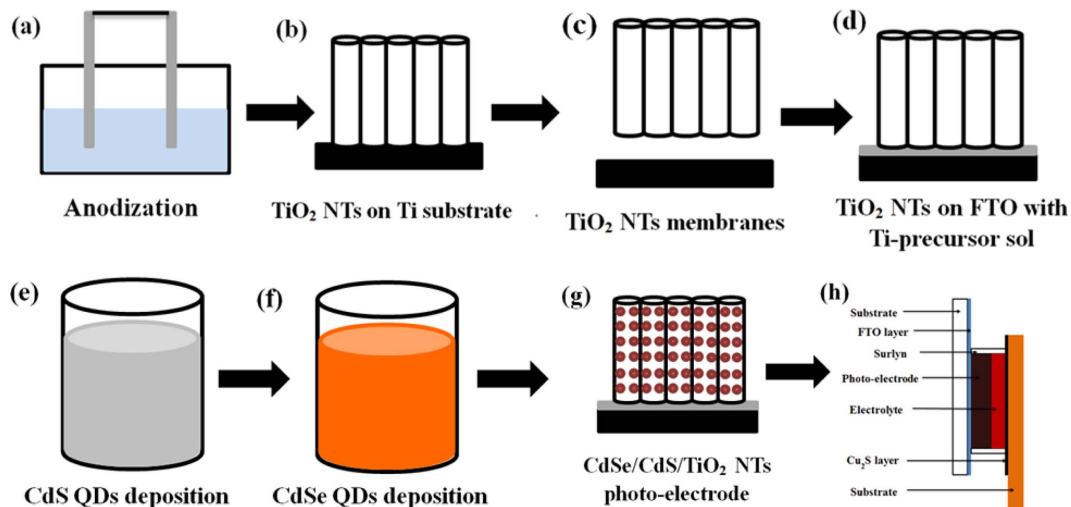


Fig. 1. Schematic of the preparation and fabrication of QDSSCs.

SILAR process (As shown in Fig. 1e and Fig. 1f). Typically, the as-prepared TiO₂ NTs electrodes were firstly immersed into a 0.1 M Cd(NO₃)₂ aqueous solution for 1 min following by distilled water washing for 1 min. And then the TiO₂ NTs electrodes were immersed in a 0.1 M Na₂S aqueous solution for 1 min following by distilled water washing for 1 min. This process was considered as one immersing cycle of SILAR procedure, which was introduced for 5 cycles to deposit CdS QDs. CdSe QDs were deposited on the prepared CdS/TiO₂ NTs electrodes by the similar process. The prepared CdS/TiO₂ NTs electrodes were firstly immersed into a 0.05 M Cd(NO₃)₂ aqueous solution for 1 min following by distilled water washing for 1 min. And then the TiO₂ NTs electrodes were immersed in a 0.05 M NaSeH₄ aqueous solution (SeO₂ into NaBH₄ aqueous solution under Ar atmosphere) for 1 min following by distilled water washing for 1 min. This process was considered as one immersing cycle of SILAR procedure, which was introduced for 11 cycles to deposit CdSe QDs. And the ZnS passivation layer was introduced by twice SILAR cycles in 0.1 M Zn(NO₃)₂ and 0.1 M Na₂S solution for 1 min per immerse, respectively. A Cu₂S films were prepared on the brass substrate as previous chemical reaction.^[19] Then the QDSSCs were fabricated with the CdSe/CdS/TiO₂ NTs electrodes and Cu₂S/brass electrodes by using a thin transparent surlyn thermoplastic frame. A methanol/distilled water (7:3 by volume) solution containing 0.5 M Na₂S, 2 M S, and 0.2 M KCl was prepared as redox polysulfide electrolyte to inject

into the sealed solar cells (As shown in Fig. 1h). The whole preparation process of QDSSCs was according to the schematic in Fig. 1.

2.3 Characterization and measurements

The scanning electron microscope (FESEM, JSEM-5610LV, Japan) were employed to characterize the morphologies of the electrodes. UV-vis absorption spectra (UV-2550, Shimadzu, Japan) were used to characterize the optical absorption properties enhancement of the electrodes. The photocurrent-voltage (*J-V*) curves were measured by the Keithley 4200 semiconductor characterization system (Keithley Instruments, USA) under AM 1.5 illumination (Newport 91160, 300 W xenon lamp, USA). The electrochemical impedance spectra (EIS) were measured by using an impedance analyzer (Auto lab PGSTAT320N) at open-circuit potentials under AM 1.5 illumination. The incident photon to current conversion efficiency (IPCE) was measured using Newport's IPCE Measurement Kit, where a monochromator was used to obtain the monochromatic light from a 300W Xe lamp (Newport).

3. RESULTS AND DISCUSSION

3.1 Structures and morphologies of CdSe/CdS/TiO₂ NTs electrodes

The TiO₂ NTs were prepared by anodization process and then transferred onto the FTO glass substrates. And then,

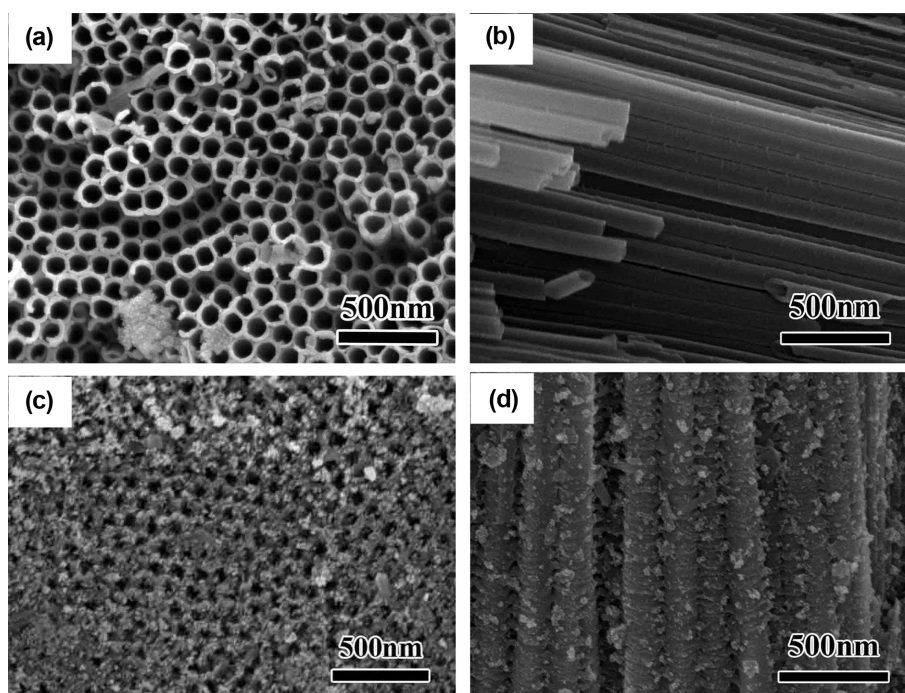


Fig. 2. FESEM images of pure TiO₂ NTs and CdSe/CdS/TiO₂ NTs photo-electrodes: (a) top-view of pure TiO₂ NTs, (b) cross-sectional of pure TiO₂ NTs, (c) top-view of CdSe/CdS/TiO₂ NTs and (d) cross-sectional of CdSe/CdS/TiO₂ NTs.

CdS and CdSe QDs were deposited on the TiO₂ NTs/FTO electrodes through the SILAR approach. Figure 2 shows the top-view and cross-sectional FESEM images of TiO₂ NTs and CdSe/CdS/TiO₂ NTs electrodes. A uniform tube structure with the average diameter of 100 nm and wall thickness of 10 nm can be clearly observed from the top-view FESEM image of pure TiO₂. Moreover, the cross-sectional image reveals the smooth and uniform vertical alignment structure of pure TiO₂. After QDs deposition, the diameter of nanotube decreased, which indicated that CdS and CdSe QDs have covered on the surface of TiO₂ NTs in the top-view FESEM image (Fig. 2c). In addition, in cross-sectional FEM image (Fig. 2d), it can be seen that QDs are also deposited on the surface of nanotube, which reveals the inner deposition of QDs in the TiO₂ nanotube.

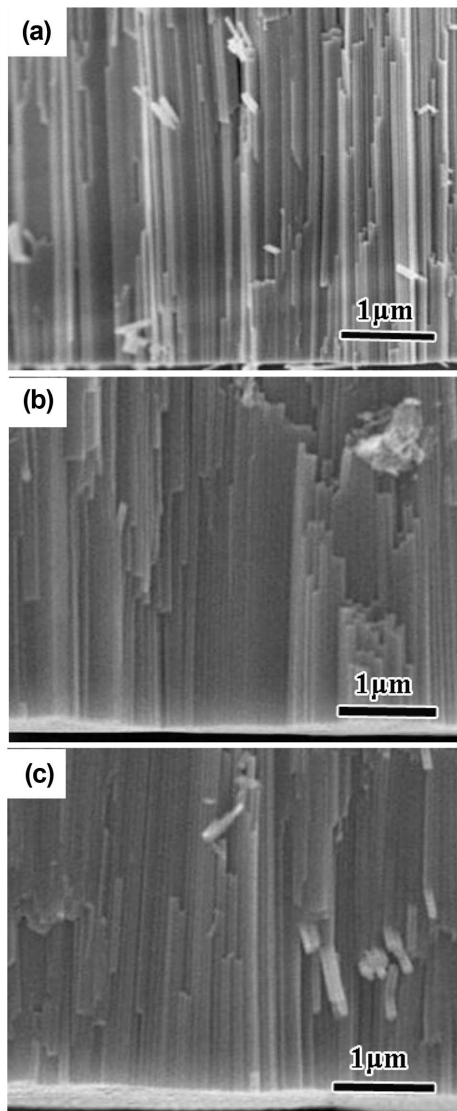


Fig. 3. FESEM images of CdSe/CdS/TiO₂ NTs photo-electrodes with different concentration of Ti-precursor: (a) 0.05 M, (b) 0.1 M and (c) 0.15 M.

3.2 Influence of sol concentration in CdSe/CdS/TiO₂ NTs solar cells

The originate TiO₂ NTs are prepared on the surface of Ti substrates, which are transferred and adhered onto the surface of FTO glass substrates with the Ti-precursor sol. Therefore, the concentration of Ti-precursor sol will seriously influence the connection between TiO₂ NTs and FTO substrates. Here, various concentrations of Ti-precursor sol containing 0.05 M, 0.1 M and 0.15 M are investigated to optimize the performance of CdSe/CdS/TiO₂ NTs photo-electrodes by employing the 20 μm – TiO₂ NTs. Figure 3 shows the FESEM images of CdSe/CdS/TiO₂ NTs photo-electrodes with different concentration of Ti-precursor sol, which can be found that the thickness of TiO₂ nanoparticle connection layer gradually increase. As shown in Fig. 3a, it can be doubted that the TiO₂ nanoparticle layer from 0.05 M Ti-precursor sol can not form well connection of TiO₂ NTs and FTO substrate. To the contrary, the TiO₂ nanoparticle layer from 0.1 M and 0.15 M Ti-precursor sol have

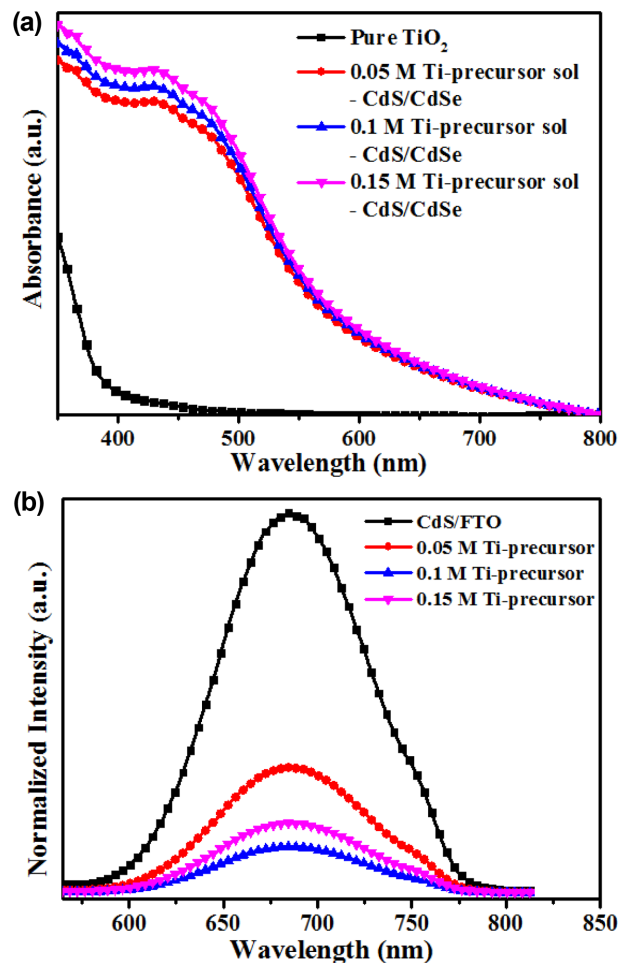


Fig. 4. Different concentration of Ti-precursor: (a) UV-vis absorption spectra of CdSe/CdS/TiO₂ NTs photo-electrodes and (b) Normalized PL spectra of CdSe/CdS/TiO₂ NTs photo-electrodes.

considerable thickness for the connection of TiO₂ NTs and FTO substrate, respectively. Therefore, relatively suitable concentration of Ti-precursor sol is very important.

Figure 4a shows the UV-vis absorption spectra of CdSe/CdS/TiO₂ NTs photo-electrodes with different concentration of Ti-precursor sol. Different from low optical absorption edge of pure TiO₂ NTs, the ultraviolet and visible light absorption edge of all three different CdSe/CdS/TiO₂ NTs photo-electrodes have greatly enhanced from 400 nm to 800 nm. And almost no distinction has been observed for the absorption edge of all these three CdSe/CdS/TiO₂ NTs photo-electrodes. However, the optical absorption intensities of the photo-electrodes are gradually increased with the concentration increasing of Ti-precursor sol. As we know, the Ti-precursor sol will form a TiO₂ nanoparticle layer on the FTO glass substrates after heat-treatment, which means that the concentration increasing of Ti-precursor sol will lead to the increasing of the thickness of TiO₂ nanoparticle layer. This may provide more carriers for the QDs deposition, inducing the enhancement of optical absorption property.

In order to observe the electron-hole separation and recombination property, CdS QDs sensitized TiO₂ NTs photo-electrodes are employed to analyze the normalized PL spectra of three different photo-electrodes in Fig. 4b. The PL peaks of CdS/FTO and three different CdS/TiO₂ NTs photo-electrodes are at the approximate wavelength of 560 nm, which indicates that different concentration of Ti-precursor sol have no effect on the PL performance of photo-electrodes. Comparing with the CdS/FTO photo-electrode, the normalized PL intensities of three different CdS/TiO₂ NTs photo-electrodes have obviously quenched, indicating the effective electron-hole separation in the CdS/TiO₂ NTs photo-electrodes system. Moreover, the normalized PL intensity of CdS/TiO₂ NTs photo-electrodes with 0.1 M Ti-precursor sol is much lower than that of 0.05 M and 0.15 M, which means that the CdS/TiO₂ NTs photo-electrodes with 0.1 M Ti-precursor sol has the best electron-hole separation property. In these three concentrations of Ti-precursor sol, the thickness of TiO₂ layer from 0.05 M Ti-precursor sol may be not enough for the well connection between TiO₂ NTs and FTO glass substrate, inducing the electron-hole recombination. Meanwhile, the thickness of TiO₂ layer from 0.15 M Ti-precursor sol may be too much, which will provide more barriers from grain boundaries between nanoparticles inducing the electron-hole recombination. Therefore, only

employing suitable concentration 0.1 M Ti-precursor sol for the TiO₂ layer can obtain the best electron-hole separation performance.

In order to investigate the photovoltaic performance of the QDSSCs fabricated through various concentrations of Ti-precursor sol, the *J-V* curves and photovoltaic parameters of the three different CdSe/CdS/TiO₂ NTs solar cells are shown in Fig. 5a and Table 1. There is no obvious distinction of open-circuit voltage (*V*_{oc}) value for three different CdSe/CdS/TiO₂ NTs solar cells (508.7 mV, 508.6 mV and 508.3 mV), indicating nothing changes for the negative potential in Fermi level of photo-electrodes under different

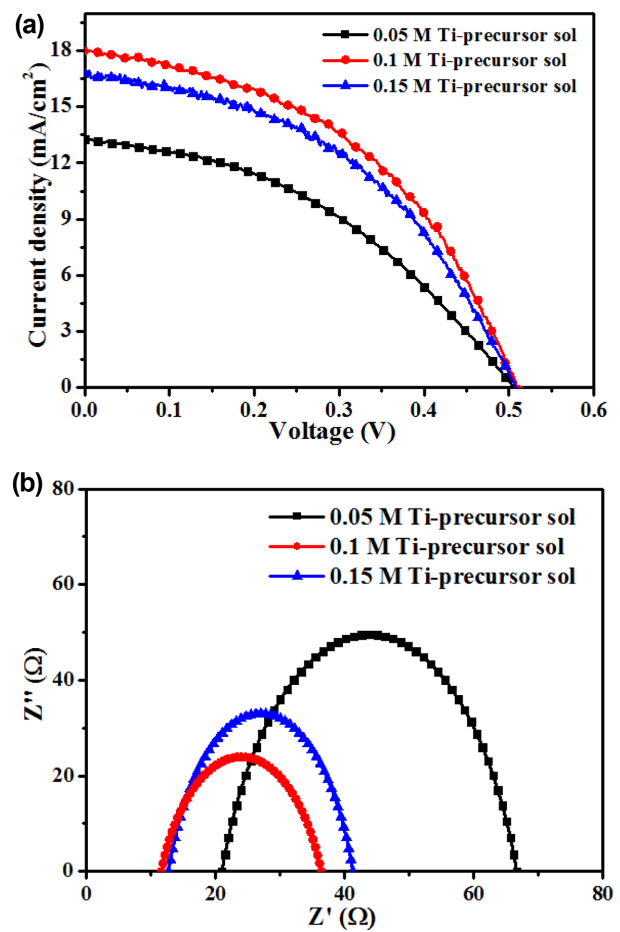


Fig. 5. Different concentration of Ti-precursor: (a) *J-V* curves of CdSe/CdS/TiO₂ NTs solar cells and (b) EIS plots of CdSe/CdS/TiO₂ NTs solar cells.

Table 1. Photovoltaic and EIS parameters of the QDSSCs with different concentration of Ti-precursor.

Ti-precursor Concentration	<i>V</i> _{oc} (mV)	<i>J</i> _{sc} (mA/cm ²)	<i>FF</i> (%)	<i>η</i> (%)	<i>R</i> _s (Ω)	<i>R</i> _{ct} (Ω)
0.05 M	508.7	13.31	40.2	2.86	21.1	45.3
0.1 M	508.6	17.96	45.8	4.18	11.7	24.5
0.15 M	508.3	16.55	46.7	3.92	12.8	28.4

concentration of Ti-precursor sol. However, the fill factor (FF) and short-circuit current density (J_{SC}) of 0.05 M Ti-precursor based CdSe/CdS/TiO₂ NTs solar cells are 0.402 and 13.31 mA/cm², which is obviously lower than that of 0.1 M and 0.15 M Ti-precursor sol based solar cells. Due to the low concentration of Ti-precursor (0.05 M), the negative connection between TiO₂ NTs and FTO glass substrate may be formed which will increase the series resistance and possibility of electron-hole recombination in photo-electrodes to reduce the FF and J_{SC} of solar cells. Comparing with QDSSCs prepared by 0.1 M and 0.15 M Ti-precursor sol, the more stable connection between TiO₂ NTs and FTO glass substrate by 0.15 M Ti-precursor sol provides the slightly higher FF of the solar cells (0.467) than that of 0.1 M Ti-precursor sol (0.458). However, 0.1 M Ti-precursor sol based CdSe/CdS/TiO₂ NTs solar cell has the higher J_{SC} value of 17.96 mA/cm². The relatively large thickness of TiO₂ layer by 0.15 M Ti-precursor sol will produce much more TiO₂ nanoparticles in the photo-electrodes system. The gain boundaries between those nanoparticles will produce more barriers to prevent the charge transfer of the solar cells. Therefore, the 0.1 M Ti-precursor sol based CdSe/CdS/TiO₂ NTs solar cell has the better photovoltaic conversion efficiency of 4.18%.

To further clarify the electron transfer performance of different Ti-precursor sol based CdSe/CdS/TiO₂ NTs solar cells, the resistance values of photo-electrodes are determined by EIS measurement in Fig. 5b and Table 1. The series resistance (R_s) of 0.1 M and 0.15 M Ti-precursor sol based CdSe/CdS/TiO₂ NTs photo-electrodes are obviously lower than that of 0.05 M Ti-precursor sol, which can demonstrate the unfavorable connection in 0.05 M Ti-precursor sol based CdSe/CdS/TiO₂ photo-electrodes and stability enhancement of CdSe/CdS/TiO₂ photo-electrodes with concentration increasing of Ti-precursor sol, further inducing the change of FF value for solar cells. Moreover, with the concentration increasing of Ti-precursor sol, the charge transfer resistances (R_{CT}) of CdSe/CdS/TiO₂ NTs photo-electrodes first increase and then decrease which match well with PL spectra in Fig. 4b. In photo-electrode systems, the unfavorable connection from 0.05 M Ti-precursor sol will reduce the path of electron transfer, and relatively excessive nanoparticles from 0.15 M Ti-precursor will induce the gain boundaries, which both increase the possibility of electron-hole recombination. On the contrary, the 0.1 M Ti-precursor sol based CdSe/CdS/TiO₂ NTs photo-electrodes not only provide stable connection for TiO₂ NTs and FTO glass substrate, but also introduce the relatively less barriers for charge transfer, finally obtaining the lowest R_s value of 11.7 Ω and R_{CT} value of 24.5 Ω . Therefore, employing the concentration of 0.1 M Ti-precursor sol can enhance the photovoltaic performance of CdSe/CdS/TiO₂ NTs solar cells.

3.3 Length influence of nanotube in CdSe/CdS/TiO₂ NTs solar cells

The thickness of thin film influences the optical property and photovoltaic performance of QDSSCs. Here the length of TiO₂ NTs (containing of 10 μ m, 15 μ m, 20 μ m and 25 μ m) have been investigated in CdSe/CdS/TiO₂ NTs solar cells by employing 0.1 M Ti-precursor sol. In Fig. 6a, with the approximate optical absorption edges, it can be seen that the UV-vis absorption intensity of CdSe/CdS/TiO₂ NTs photo-electrodes are gradually enhanced with the length increasing of TiO₂ NTs. However, the UV-vis absorption intensity of 25 μ m - CdSe/CdS/TiO₂ NTs photo-electrode is slightly higher than that of 20 μ m, which can be assumed that the prolonged 5 μ m of TiO₂ NTs is unnecessary for the optical absorption. Fig. 6b shows the normalized PL spectra of CdS/TiO₂ NTs photo-electrodes with different length of TiO₂ NTs. Comparing with pure CdS/FTO electrodes, the normalized PL peaks of all the CdS/TiO₂ NTs photo-electrodes are obviously quenched to the approximate PL

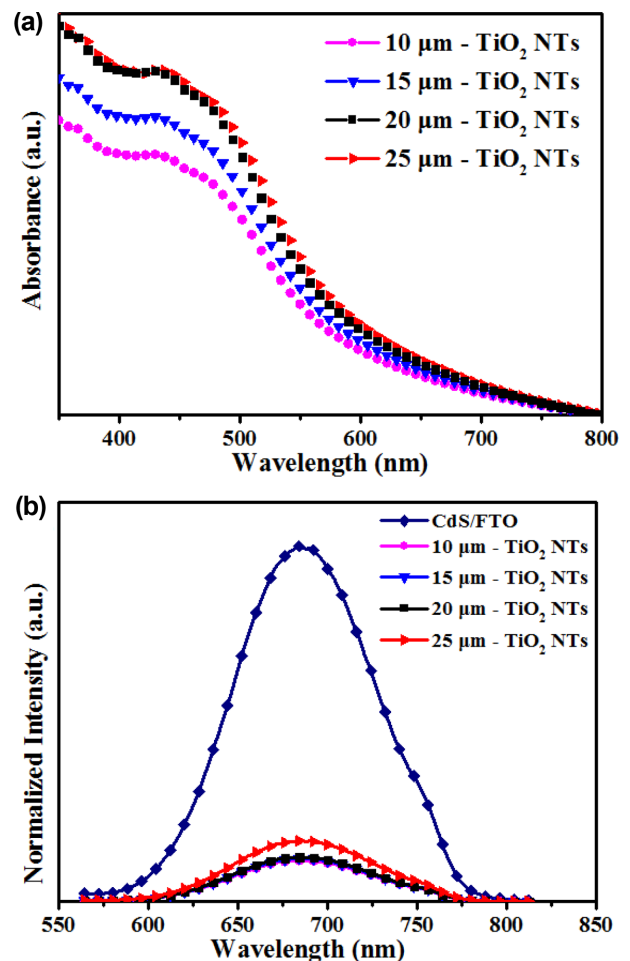


Fig. 6. Different length of TiO₂ NTs: (a) UV-vis absorption spectra of CdSe/CdS/TiO₂ NTs photo-electrodes and (b) Normalized PL spectra of CdSe/CdS/TiO₂ NTs photo-electrodes.

intensity except 25 μm - CdS/TiO₂ NTs photo-electrode. The PL intensity of 25 μm - CdS/TiO₂ NTs photo-electrode is higher than other length of TiO₂ NTs, which may be attributed to the relatively excessive length of TiO₂ NTs to increase the possibility of electron-hole recombination. Therefore, it can be considered that the 20 μm - CdSe/CdS/TiO₂ NTs photo-electrode may be better to obtain excellent photovoltaic performance of the solar cells.

The J - V curves, EIS plots and photovoltaic parameters are measured in Fig. 7 and Table 2. There have approximate V_{OC} and FF values for all the CdSe/CdS/TiO₂ NTs solar cells

with different length of TiO₂ NTs, as well as the similar results for the R_s values of CdSe/CdS/TiO₂ NTs photo-electrodes. For comparison, the J_{SC} values of CdSe/CdS/TiO₂ NTs solar cells first increase then decrease with the length increasing of TiO₂ NTs, which have the highest J_{SC} value of 17.96 mA/cm^2 at the length of 20 μm . With the length increasing of TiO₂ NTs, the quantity of QDs deposition are gradually increased, which can provide much more photo-induced electrons for the photo-electrodes to improve the current density of the solar cells. However, although the 25 μm - CdSe/CdS/TiO₂ NTs photo-electrode

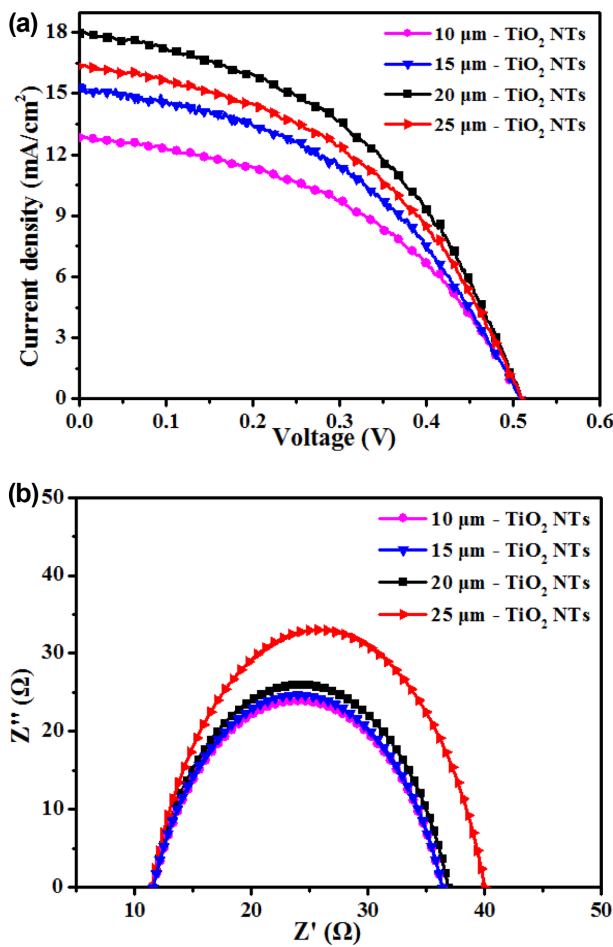


Fig. 7. Different length of TiO₂ NTs: (a) J - V curves of CdSe/CdS/TiO₂ NTs solar cells and (b) EIS plots of CdSe/CdS/TiO₂ NTs solar cells.

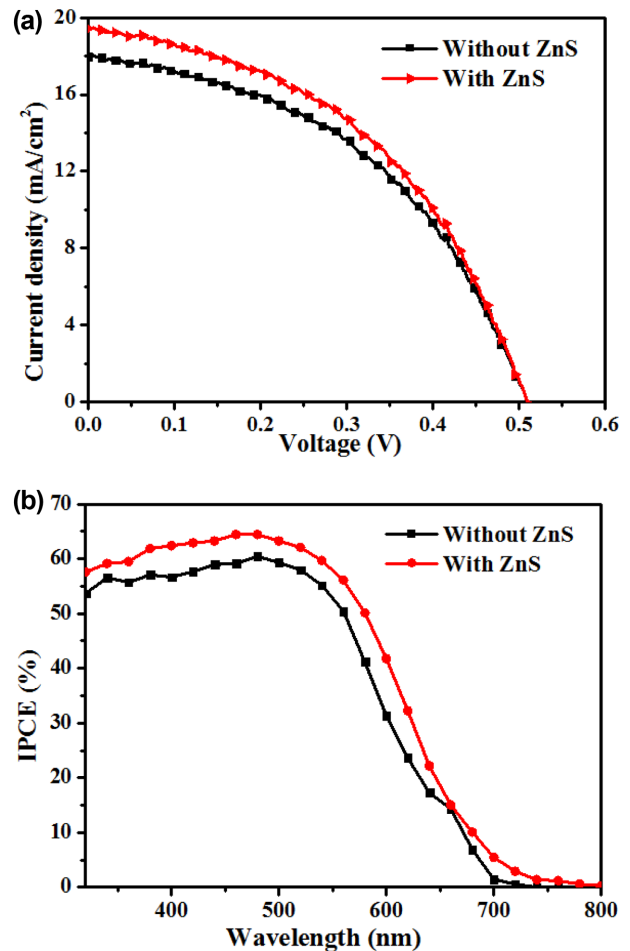


Fig. 8. With ZnS passivation layer: (a) J - V curves of CdSe/CdS/TiO₂ NTs solar cells; (b) IPCE spectra of CdSe/CdS/TiO₂ NTs solar cells.

Table 2. Photovoltaic and EIS parameters of the QDSCs with different length of TiO₂ NTs.

Length of TiO ₂ NTs	V_{OC} (mV)	J_{SC} (mA/cm^2)	FF (%)	η (%)	R_s (Ω)	R_{CT} (Ω)
10 μm	508.3	12.84	45.6	2.97	11.4	23.7
15 μm	508.2	15.31	45.2	3.54	11.5	23.9
20 μm	508.6	17.96	45.8	4.18	11.7	24.5
25 μm	509.1	16.35	45.5	3.78	11.6	28.6

have excellent optical absorption property, some part of relatively excessive length of 25 μm - CdSe/CdS/TiO₂ NTs photo-electrode may not capture photon to generate electron-holes, which will become the barrier of charge transfer and center of charge recombination in the solar cells to decrease the J_{SC} value (16.35 mA/cm²). Therefore, due to the advantages of charge generation and transfer performance, higher J_{SC} value can be obtained by 20 μm - CdSe/CdS/TiO₂ NTs solar cells. Furthermore, the R_{CT} values of CdSe/CdS/TiO₂ NTs photo-electrodes have the similar tendency of J_{SC} values. The R_{CT} values of 10 μm , 15 μm and 20 μm - CdSe/CdS/TiO₂ NTs photo-electrode have slightly increased (23.7 Ω , 23.9 Ω and 24.5 Ω), which indicates that there have few effect for the charge transfer performance of these three photo-electrodes with the length increasing of TiO₂ NTs. However, the R_{CT} value of the 25 μm - CdSe/CdS/TiO₂ NTs photo-electrode is obviously higher than that of three photo-electrodes, which can be believed the barrier of charge transfer in the relatively long length of TiO₂ NTs. Those results demonstrate that the 20 μm - CdSe/CdS/TiO₂ NTs photo-electrodes can provide better photovoltaic performance of solar cells.

After the optimizations of the photo-electrode, the 20 μm - CdSe/CdS/TiO₂ NTs solar cells with 0.1 M Ti-precursor have received the photovoltaic conversion efficiency of 4.18%. In order to further enhance photovoltaic efficiency of the solar cells, the traditional ZnS passivation layer is prepared on the surface of CdSe/CdS/TiO₂ NTs photo-electrodes. In Fig. 8a, with nothing influence for the V_{OC} and FF values, it can be seen that the J_{SC} values have obviously enhanced after the ZnS passivation layer deposition, final indicating the photovoltaic efficiency to 4.51%. And the IPCE spectra of CdSe/CdS/TiO₂ NTs solar cells Fig. 8b cover the whole optical wavelength of 300-800 nm, which match well with the UV-vis absorption spectra in Fig. 4a. And the IPCE value of the CdSe/CdS/TiO₂ NTs solar cells with ZnS passivation layer is higher than that of pure CdSe/CdS/TiO₂ NTs solar cells, which can support the photovoltaic performance enhancement in the whole ultraviolet and visible light region.

4. CONCLUSIONS

In summary, the CdSe/CdS/TiO₂ NTs solar cells have been successfully prepared on the FTO glass substrates, and concentration of Ti-precursor and length of TiO₂ NTs have been optimized to enhance the performance of the as-fabricated solar cells. The charge transfer and photovoltaic performance of 0.1 M Ti-precursor based CdSe/CdS/TiO₂ NTs solar cells are obviously improved, which is due to the barrier of charge transfer from the relatively low concentration of 0.05 M and high concentration of 0.15 M Ti-precursor. With the concentration of 0.1 M Ti-precursor, the 20 μm -

CdSe/CdS/TiO₂ NTs solar cells have the best photovoltaic performance, which is attributed to the relatively higher optical absorption property and lower possibility of electron-hole recombination from suitable length of TiO₂ NTs. After the ZnS passivation layer deposition, the optimized CdSe/CdS/TiO₂ NTs solar cells have received the excellent photovoltaic efficiency of 4.51%. It can be believed that TiO₂ NTs arrays can effectively instead nanoparticles for excellent photovoltaic devices by this process.

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